



IFW

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q88662

Takenori OSADA, et al.

Appln. No.: 10/540,513

Group Art Unit: 2826

Confirmation No.: 6641

Examiner: Eduardo A. Rodela

Filed: June 23, 2005

For: COMPOUND SEMICONDUCTOR EPITAXIAL SUBSTRATE AND METHOD FOR
MANUFACTURING THE SAME

AMENDMENT UNDER 37 C.F.R. § 1.111

MAIL STOP AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated June 7, 2006, please amend the above-identified
application as follows on the accompanying pages.

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